

***Klebsiella pneumoniae*, Strain BWH 15**

Catalog No. NR-41898

Product Description:

Klebsiella pneumoniae (*K. pneumoniae*), strain BWH 15 was isolated in 2012 from the peritoneal fluid of a human in Boston, Massachusetts, USA. NR-41898 was produced by inoculation of BEI Resources seed lot 70007972 into Tryptic Soy broth and grown for 1 day at 37°C in an aerobic atmosphere. Broth inoculum was added to Tryptic Soy agar kolles, which were grown for 1 day at 37°C in an aerobic atmosphere to produce this lot.

Lot: 70061544

Manufacturing Date: 23JUN2023

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E-mail: Contact@BEIResources.org. We try to respond to feedback within 24 hours.

TEST	SPECIFICATIONS	RESULTS
Phenotypic Analysis Cellular morphology Colony morphology Motility (wet mount) VITEK® 2 MS (MALDI-TOF)	Gram-negative rods Report results Report results <i>K. pneumoniae</i>	Gram-negative rods Circular, convex, entire, smooth mucoid and cream Non-motile <i>K. pneumoniae</i> (99%)
Antibiotic Susceptibility Profile Etest® antibiotic test strips ¹ 1 day at 37°C in an aerobic atmosphere on Mueller Hinton agar Ceftriaxone Tobramycin VITEK® (AST-GN83 Card) ² Ampicillin Amoxicillin/clavulanic acid Ampicillin/sulbactam Piperacillin/tazobactam Cefazolin Cefuroxime Cefuroxime axetil Cefoxitin Cefotaxime Ceftazidime Ceftriaxone Cefepime Aztreonam Meropenem Amikacin Gentamicin Ciprofloxacin Nitrofurantoin Trimethoprim/sulfamethoxazole	Resistant Sensitive Resistant Resistant Resistant Resistant Resistant Resistant Resistant Resistant Resistant Resistant Resistant Resistant Resistant Resistant Resistant Resistant Sensitive Sensitive Sensitive Intermediate Resistant	Resistant (16 µg/mL) Sensitive (1 µg/mL) Resistant (≥ 32 µg/mL) Resistant (≥ 32 µg/mL) Resistant (≥ 32 µg/mL) Resistant (≥ 128 µg/mL) Resistant (≥ 64 µg/mL) Resistant (≥ 64 µg/mL) Resistant (≤ 4 µg/mL) Resistant (≥ 64 µg/mL) Resistant (≥ 64 µg/mL) Resistant (≥ 64 µg/mL) Resistant (2 µg/mL) Resistant (≥ 64 µg/mL) Resistant (≥ 16 µg/mL) Sensitive (≤ 2 µg/mL) Sensitive (4 µg/mL) Sensitive (≤ 0.25 µg/mL) Intermediate (64 µg/mL) Resistant (≥ 320 µg/mL)
Genotypic Analysis Sequencing of 16S ribosomal RNA gene (~ 1470 base pairs)	≥ 99% sequence identity to <i>K. pneumonia</i> , strain BWH 15 GenBank: JCNP01000018.1)	99.3% sequence identity to <i>K. pneumonia</i> , strain BWH 15 (GenBank: JCNP01000018.1)

TEST	SPECIFICATIONS	RESULTS
Purity (post-freeze) 7 days at 37°C in an aerobic atmosphere with 5% CO ₂ on Tryptic Soy agar with 5% defibrinated sheep blood	Growth consistent with expected colony morphology	Growth consistent with expected colony morphology
Viability (post-freeze)	Growth	Growth

¹Minimum Inhibitory Concentration (MIC); MIC Interpretation Guideline: CLSI M100-S28 (2018)

²MIC interpretation was determined using VITEK® 2 software version 09.01 combined with the bioMérieux Advanced Expert System™ (AES) software using the interpretation standard CLSI M100-S28 (2018) and the interpretation guideline "Natural Resistance." For more information, please refer to Sanders, C. C., et al. "Potential Impact of the VITEK 2 System and the Advanced Expert System on the Clinical Laboratory of a University-Based Hospital." *J. Clin. Microbiol.* 39 (2001): 2379-2385. PubMed: 11427542.

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12 SEP 2023

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